

AMENDMENTS TO THE SPECIFICATION

Please replace the paragraph beginning on line 27, page 8 of the specification with the following amended paragraph:

Weak locations 44d (also referred to herein as wells) are also provided in the applicator plate 44 in raster grid configuration at equidistant spacings in the spaces between two successive grooves 44c, or a groove 44c and the associated edge of the applicator plate 44. Those weak locations 44d are formed by circular depressions, as can be seen from Figure 4. As shown in more detail in Figure 5, at the side 44e of the applicator plate 44 that faces towards the carrier plate 42 the applicator plate 44 is provided in a manner corresponding to the material weak locations 44d, with further material weak locations 44f (again, also referred to herein as wells), which are also circular depressions. The material weak locations 44d, 44f which are oriented in mutually coaxial relationship are separated by a thin material skin or wall portion 44g, which extends in transverse relationship to their axial direction. The thin material skin portions 44g exclude a flow communication between the two material weak locations 44d, 44f which belong to each other, in particular after production of the applicator head 10 in the factory. In other words, the applicator head 10 or the applicator pad 40 which can be replaceably inserted into the applicator head 10 cannot initially be used after manufacture as there is no flow communication between the applicator surface 44b and the suction air source.